



SEC. 506

OK 3/24/03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of:

Byoung-taek LEE et al.

Group Art Unit: 2823

Serial No.: 09/276,803

Examiner: Neal BEREZNY

Filed: 26 March 1999

METHOD FOR MANUFACTURING
CAPACITOR OF SEMICONDUCTOR
DEVICE HAVING DIELECTRIC
LAYER OF HIGH DIELECTRIC
CONSTANT

RECEIVED
FEB 18 2003
TECHNOLOGY CENTER 2800

AMENDMENT UNDER 37 C.F.R. § 1.112

Honorable Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the Office Action dated 13 September 2002, the period for response is hereby being extended by the accompanying Petition and Petition Fee to 13 February 2003, please amend the above-identified patent application as follows:

IN THE CLAIMS:

Please substitute the following claims for the pending claims with the same claim numbers.

Ref Wnt
1. (Twice Amended) A method for manufacturing a capacitor of a semiconductor device, comprising: